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(71) Applicant (for all designated States except US): **MATRIX LABORATORIES LTD** [IN/IN]; 1-1-151/1, IV Floor, Sairam Towers, Alexander Road, Secunderabad 500 003, Andhra Pradesh (IN).

(72) Inventors; and

(75) Inventors/Applicants (for US only): **RAMAN-JANEYULU**, Gorantla, Seeta [IN/IN]; Plot No-12, Sai Ansh Arcade, Durgavihar Colony, Tirumalgherry, Secunderabad 500 015 (IN). **KUMAR**, Indukuri, Venkata, Sunil [IN/IN]; Flat No-104, Raghavendra Towers, KPHB - VI Phase, Kukatpally, Hyderabad 500 072 (IN). **RAO**, Ketavarapu, Narasimha [IN/IN]; C3-521, Huda Colony, Chandanagar, Hyderabad 500 050 (IN). **KISHORE**, Jammula, Vera, Venkata, Krishna [IN/IN]; Flat No-102B, Vivekananda Apartments, Vivekananda Nagar Colony, Hyderabad 500 072 (IN).

(74) Common Representative: **MATRIX LABORATORIES LTD**; RAO, CH., V. Ramana, Plot No. 38, Phase IV, Ida, Jeedimetla 500 055, Hyderabad (IN).

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(54) Title: PROCESS FOR THE PREPARATION OF CARVEDILOL FORM-II

(57) Abstract: The present invention provides a cost-effective, industrially feasible process for the manufacture of crystalline Carvedilol Form-II using novel Carvedilol salts comprising a step of reacting 4-(2,3-epoxy propoxy) carbazole (II) with 2-(2-methoxy phenoxy) ethyl amine (III) followed by acidification with mineral acid in presence of an organic solvent to yield acid addition salts, treatment of the said salts with base(s) in presence of organic solvent(s), water and isolation from the organic solvent(s) followed by crystallization from ethyl acetate.

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